

Fundamentals of Nanotransistors

Unit 3: The Ballistic Nanotransistor

Lecture 3.1: Introduction

Mark Lundstrom

lundstro@purdue.edu

Electrical and Computer Engineering

Birck Nanotechnology Center

Purdue University, West Lafayette, Indiana USA

Unit 3

Lecture 3.1: Introduction

Lecture 3.2: Landauer Approach

Lecture 3.3: More on Landauer

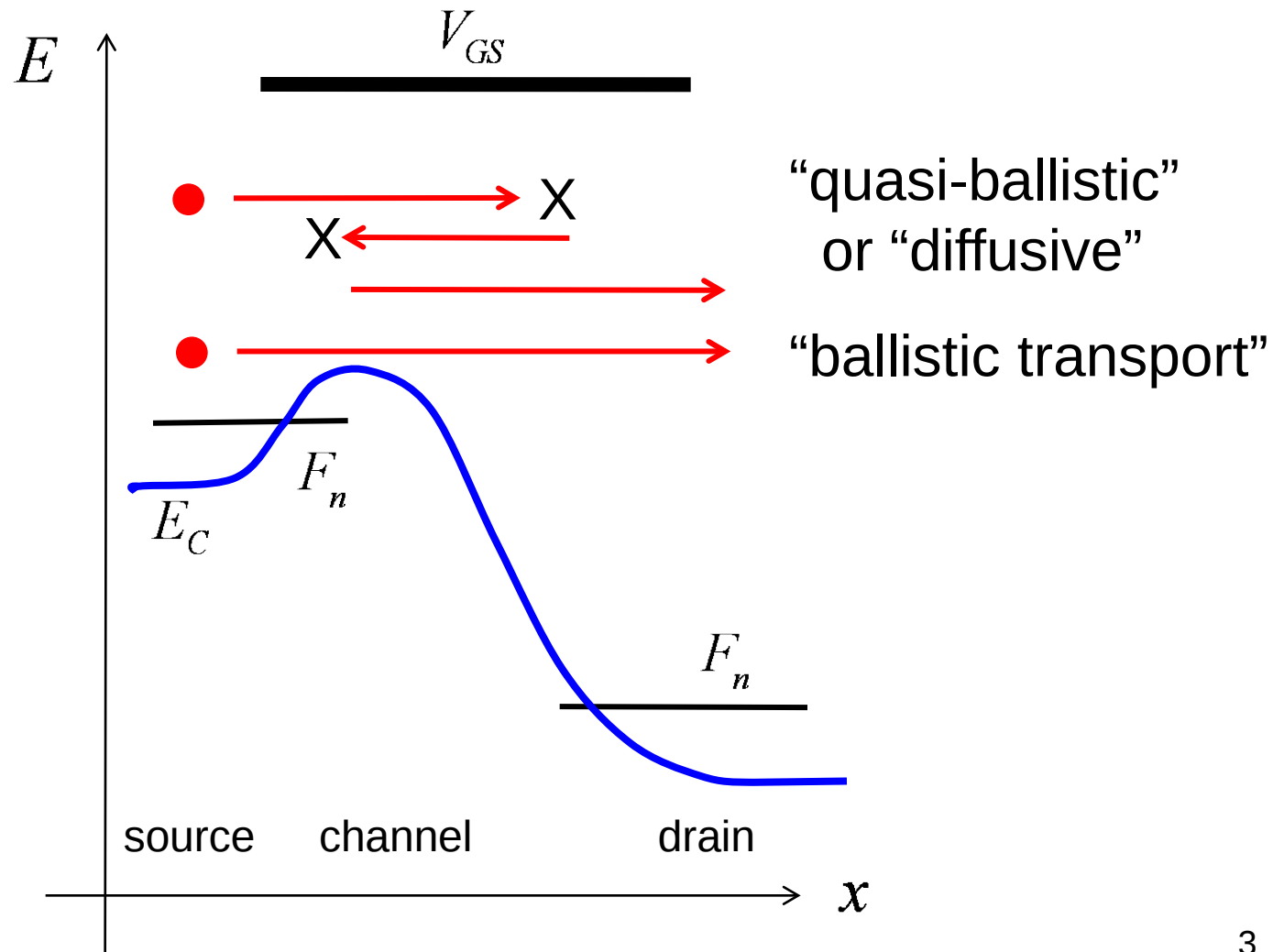
Lecture 3.4: The Ballistic MOSFET

Lecture 3.5: The Velocity at the VS

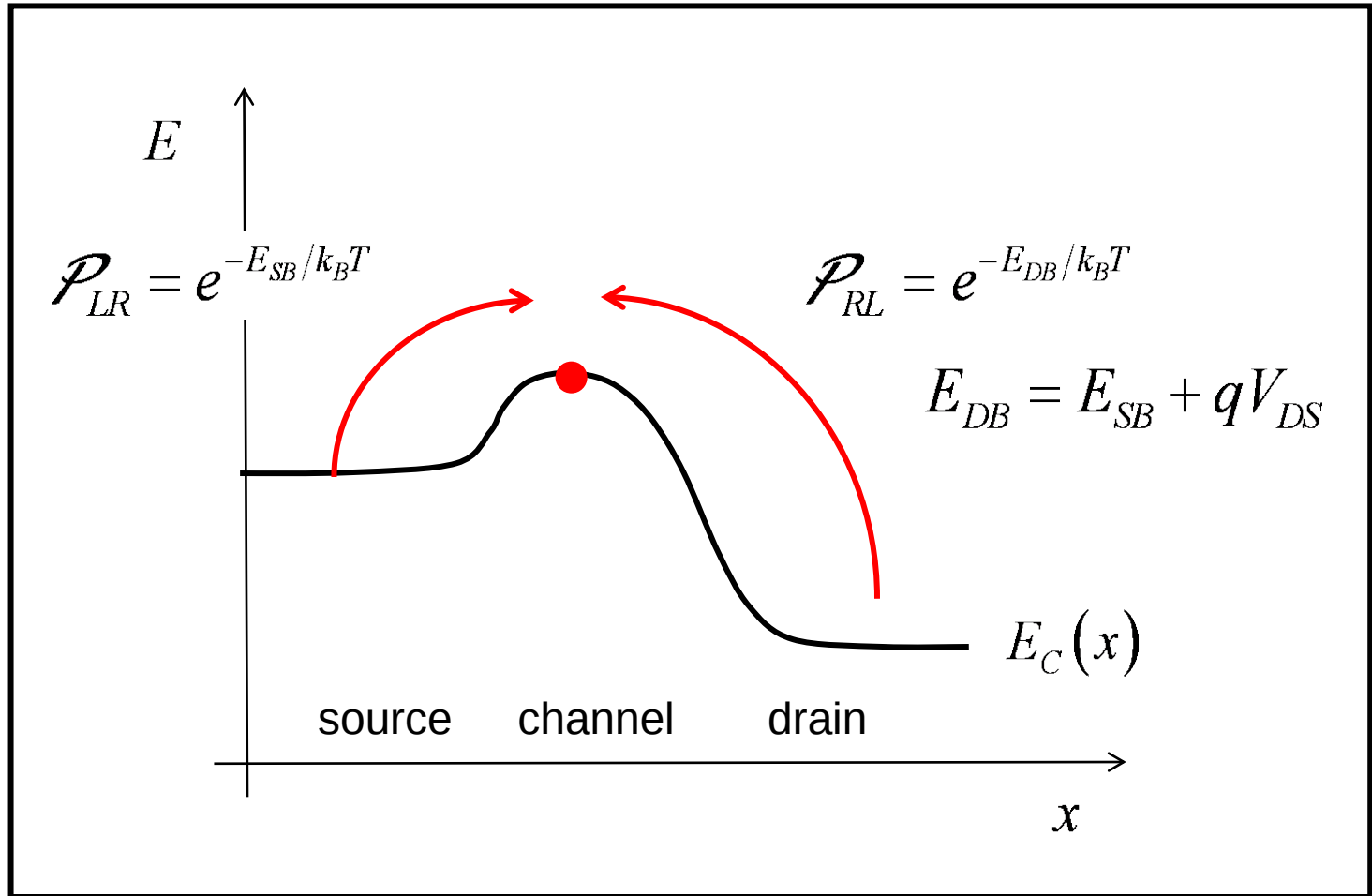
Lecture 3.6: Revisiting the VS Model

Lecture 3.7 Summary

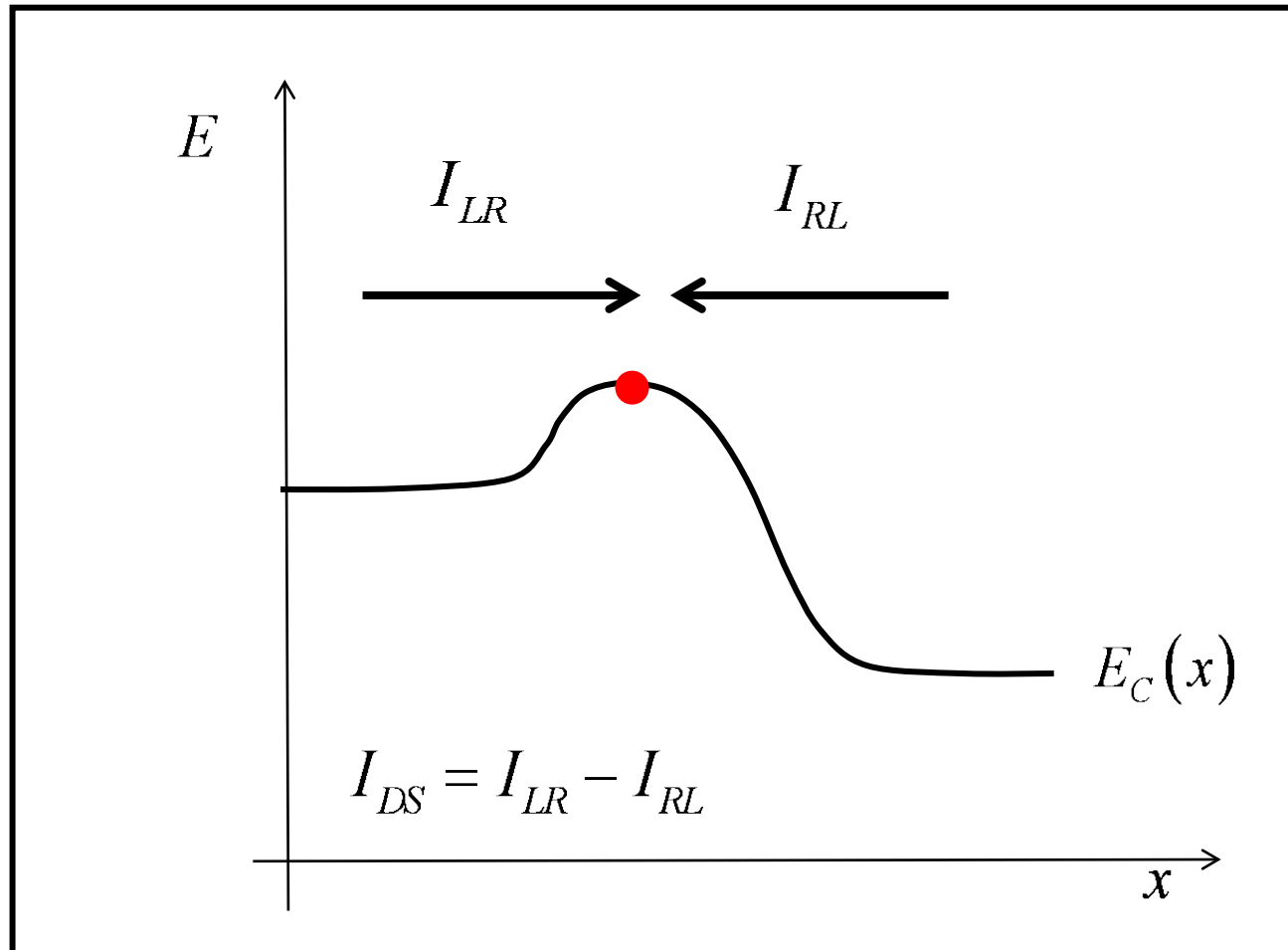
Ballistic vs. diffusive transport



Thermionic emission



Thermionic emission



Ballistic current

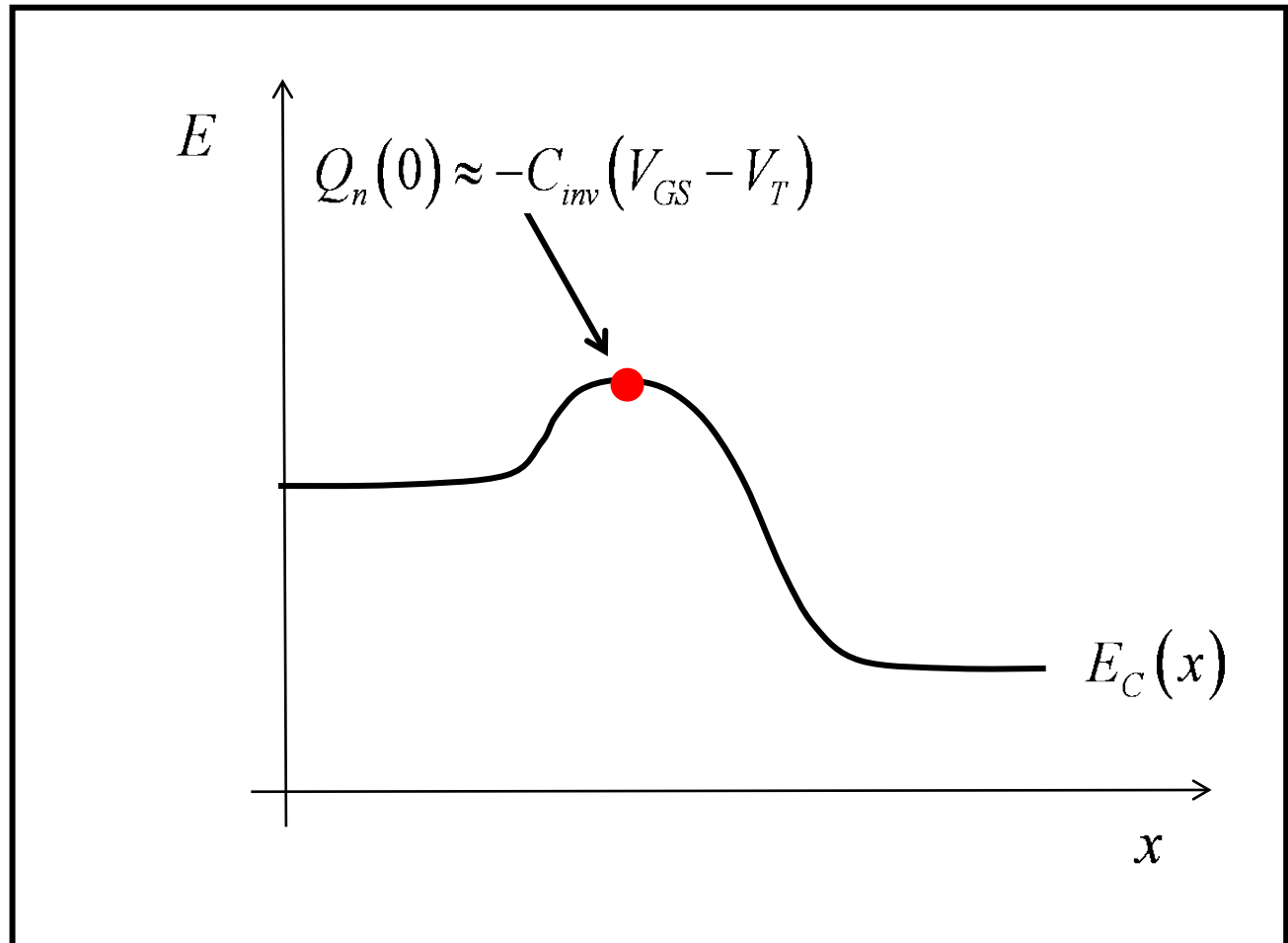
$$I_{DS} = I_{LR} - I_{RL}$$

$$I_{DS} = I_{LR} \left(1 - I_{RL} / I_{LR} \right)$$

$$I_{DS} = I_{LR} \left(1 - e^{-qV_{DS}/k_B T} \right)$$

$$I_{DS} = I_{LR} \left(1 - e^{-\Delta E_B / k_B T} \right)$$

MOS electrostatics



MOS electrostatics

$$I_{LR} = Wqn_S^+v_T$$

$$Q_n = -q(n_S^+ + n_S^-)$$

$$I_{RL} = Wqn_S^-v_T$$

$$Q_n = -\frac{(I_{LR} + I_{RL})}{Wv_T}$$

$$qn_S^+ = \frac{I_{LR}}{Wv_T}$$

$$Q_n = -\frac{I_{LR}}{Wv_T} \left(1 + I_{RL}/I_{LR}\right)$$

$$qn_S^- = \frac{I_{RL}}{Wv_T}$$

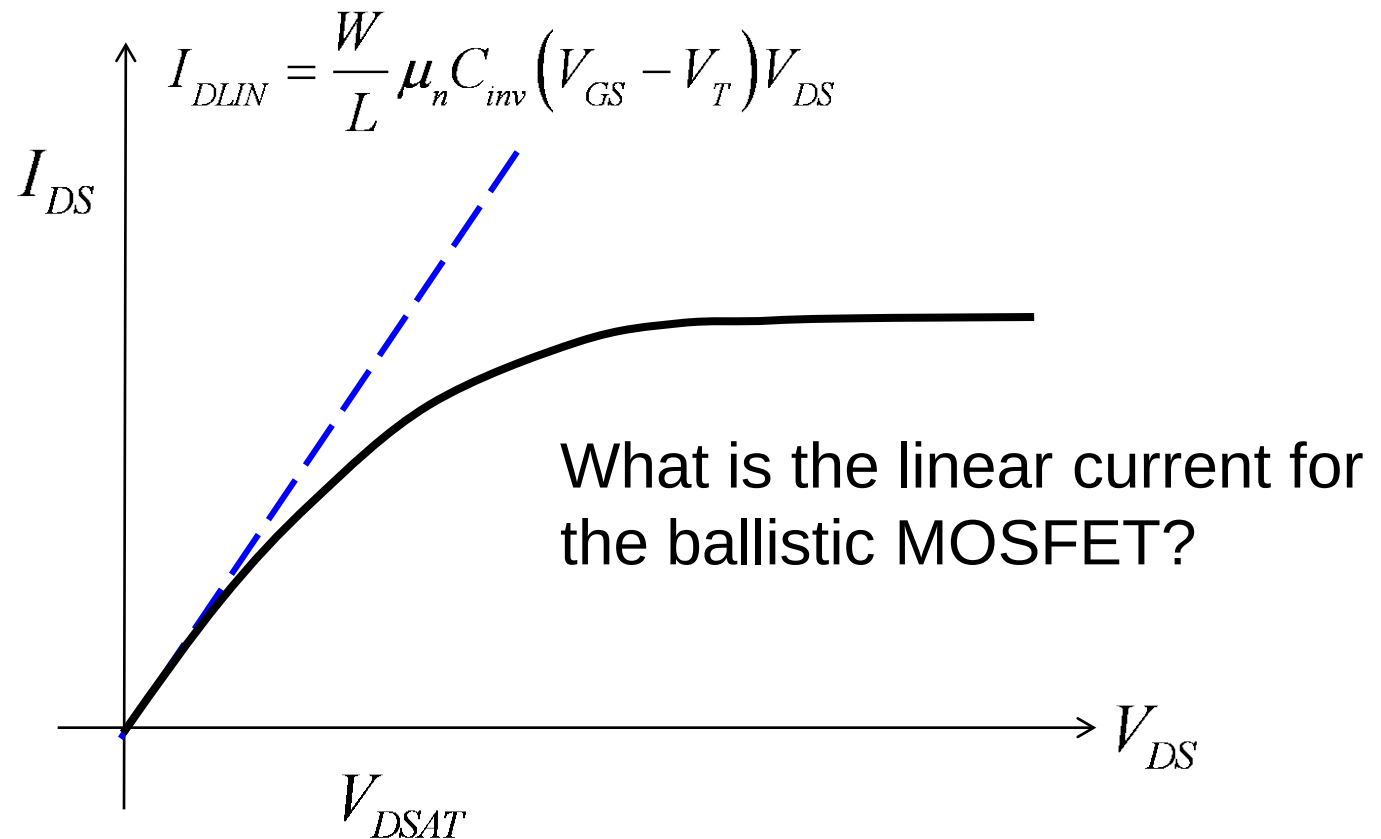
$$Q_n = -\frac{I_{LR}}{Wv_T} \left(1 + e^{-qV_{DS}/k_B T}\right)$$

Ballistic IV characteristics

$$I_{DS} = I_{LR} \left(1 - e^{-qV_{DS}/k_B T}\right) \quad Q_n(0) = -\frac{I_{LR}}{W v_T} \left(1 + e^{-qV_{DS}/k_B T}\right)$$

$$I_{DS} = W |Q_n(0)| v_T \frac{\left(1 - e^{-qV_{DS}/k_B T}\right)}{\left(1 + e^{-qV_{DS}/k_B T}\right)}$$

Recall: traditional model in linear region



Ballistic MOSFET: Linear region

$$I_{DS} = W |Q_n(0)| v_T \frac{(1 - e^{-qV_{DS}/k_B T})}{(1 + e^{-qV_{DS}/k_B T})}$$

$$V_{DS} \ll k_B T / q$$

$$e^x \approx 1 + x \quad (\text{small } x)$$

$$I_{DS} = W |Q_n(0)| \frac{v_T}{2(k_B T / q)} V_{DS}$$

$$I_{DS} = W |Q_n(0)| v_T \frac{1 - (1 - qV_{DS}/k_B T)}{1 + (1 - qV_{DS}/k_B T)}$$

Traditional vs. ballistic linear current

Diffusive

$$I_{DLIN} = \frac{W}{L} \mu_n |Q_n(x=0)| V_{DS}$$

$$I_{DLIN} = \frac{W}{L} \mu_n C_{inv} (V_{GS} - V_T) V_{DS}$$

Ballistic

$$I_{DLIN}^{ball} = W \left(\frac{v_T}{2(k_B T/q)} \right) |Q_n(x=0)| V_{DS}$$

$$I_{DLIN}^{ball} = W \left(\frac{v_T}{2(k_B T/q)} \right) C_{inv} (V_{GS} - V_T) V_{DS}$$

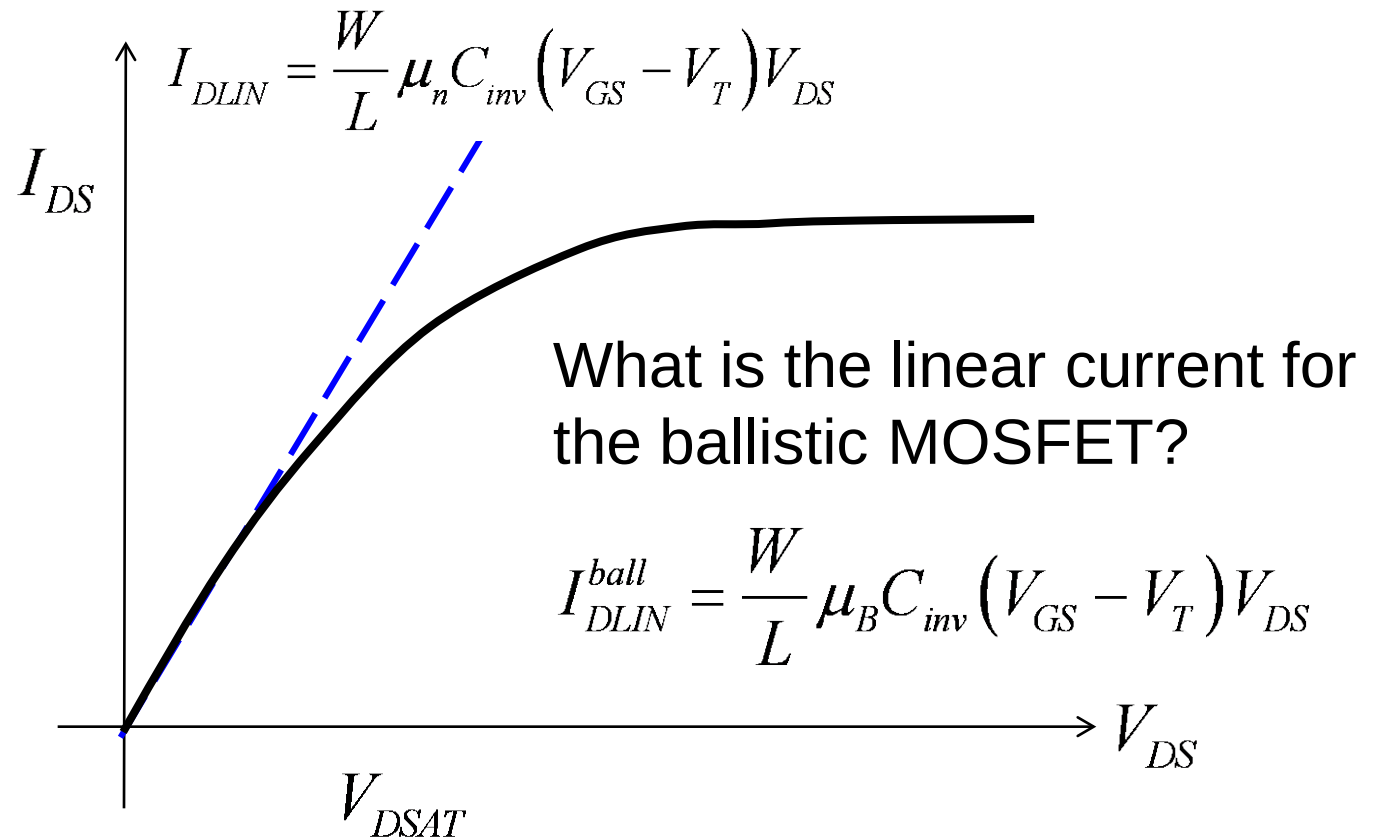
$$I_{DLIN}^{ball} = \frac{W}{L} \left(\frac{v_T L}{2(k_B T/q)} \right) |Q_n(x=0)| V_{DS}$$

Independent of L

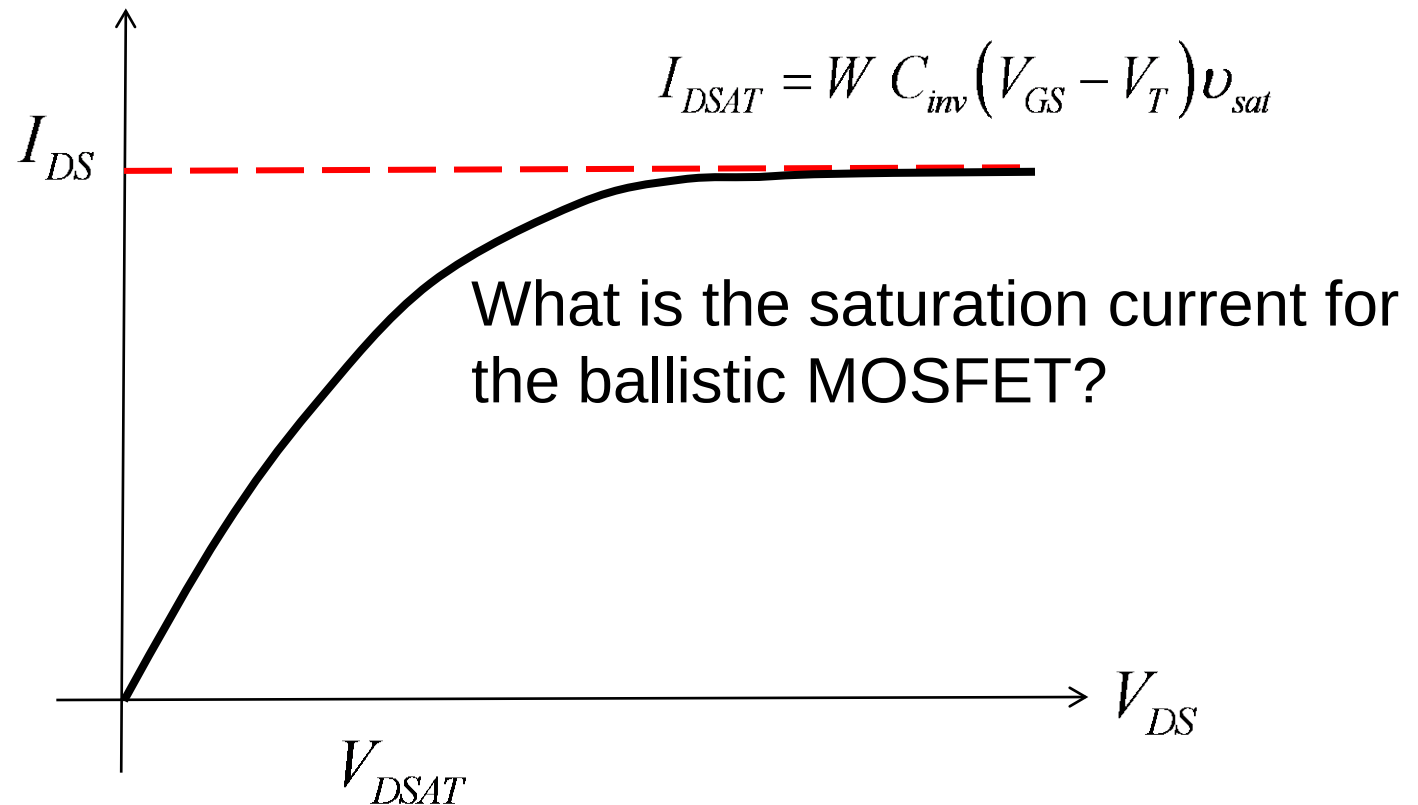
$$\mu_B \equiv \frac{v_T L}{2(k_B T/q)}$$

“ballistic mobility”

Ballistic model in linear region



Recall: Traditional model in saturation



Ballistic MOSFET: Saturation region

$$I_{DS} = W |Q_n(0)| v_T \frac{(1 - e^{-qV_{DS}/k_B T})}{(1 + e^{-qV_{DS}/k_B T})}$$

$$V_{DS} \gg k_B T / q$$

$$e^{-x} \approx 0 \quad (\text{large } x)$$

$$I_{DSAT} = W |Q_n(0)| v_T$$

$$I_{DS} = W |Q_n(0)| v_T$$

Traditional vs. ballistic saturation current

Diffusive

$$I_{DSAT} = W |Q_n(x=0)| v_{sat}$$

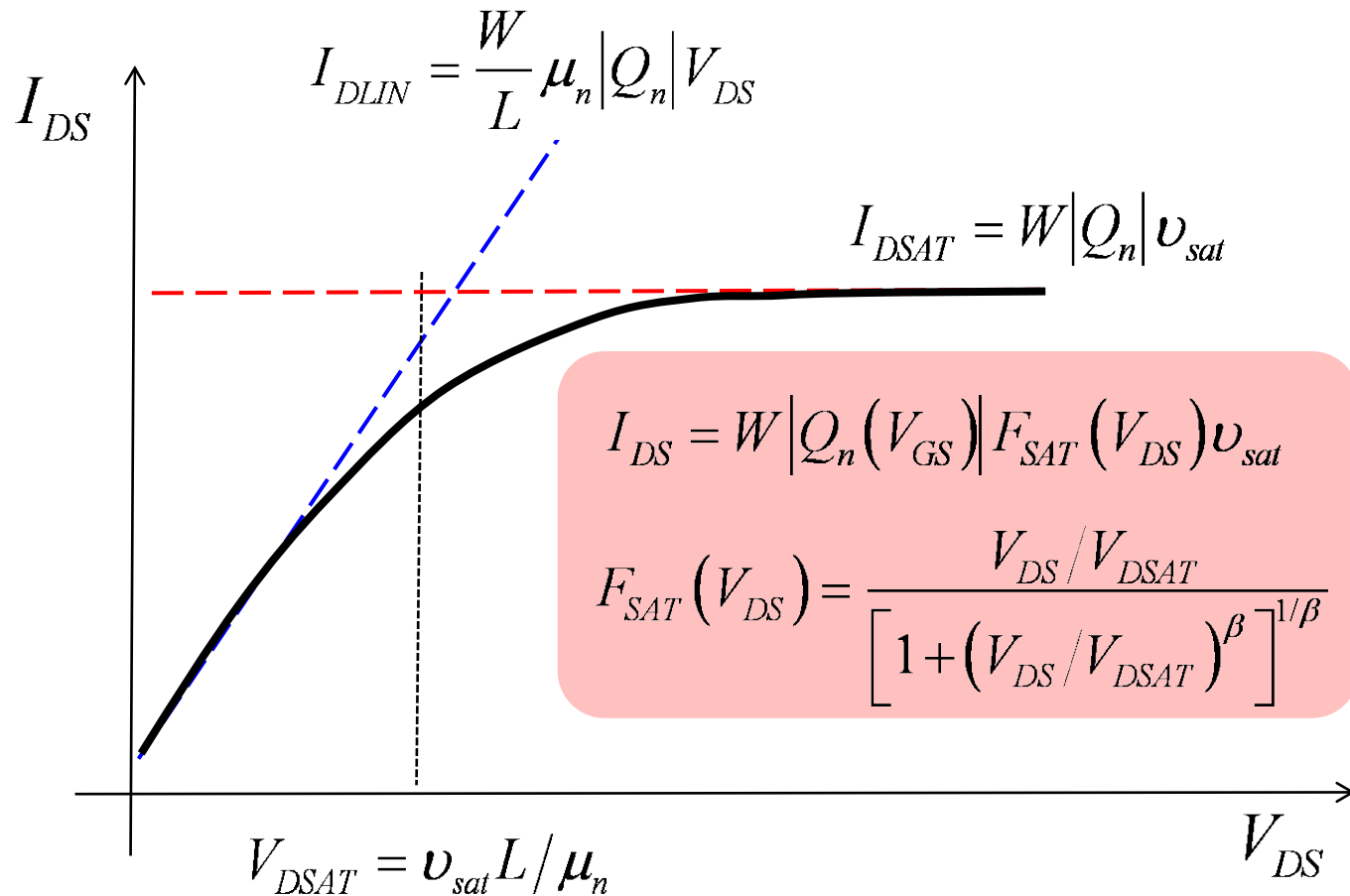
$$I_{DSAT} = W C_{inv} (V_{GS} - V_T) v_{sat}$$

Ballistic

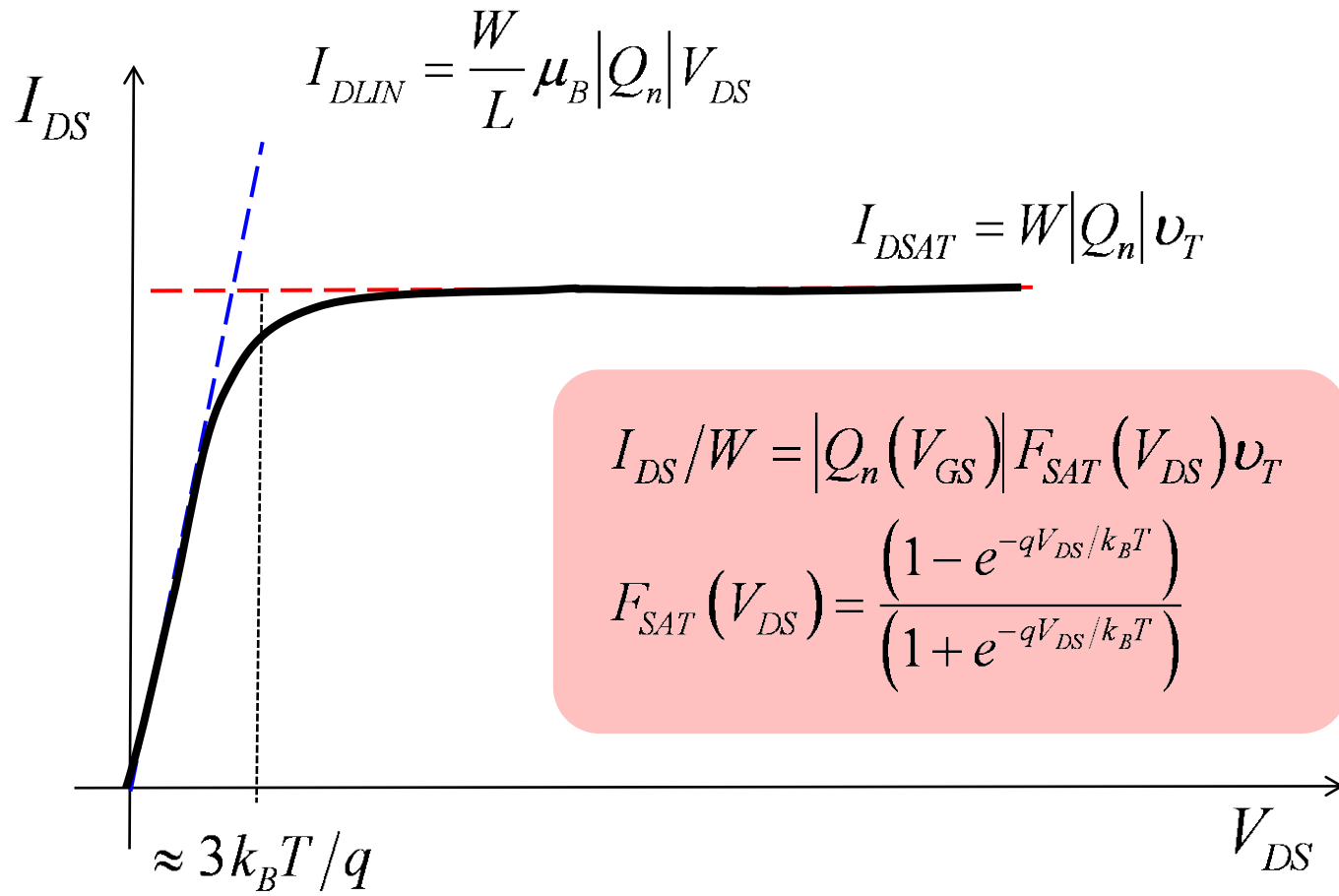
$$I_{DSAT} = W |Q_n(x=0)| v_T$$

$$I_{DSAT} = W C_{inv} (V_{GS} - V_T) v_T$$

Recall: VS model



Ballistic model



The ballistic MOSFET

$$I_{DS} = W |Q_n(0)| v_T \frac{(1 - e^{-qV_{DS}/k_B T})}{(1 + e^{-qV_{DS}/k_B T})}$$

Assumptions:

- 1) Non-degenerate (Boltzmann) statistics for carriers
- 1) No scattering

Transport

1) Drift-diffusion equation:

$$J_n = nq\mu_n \mathcal{E} + qD_n \frac{dn}{dx}$$

2) Landauer approach:

$$I = \frac{2q}{h} \int \mathcal{T}(E) M(E) (f_1 - f_2) dE$$

Next lecture: Introduce the Landauer approach.